



**REPLY UNDER 37 C.F.R. 1.116 – EXPEDITED PROCEDURE
TECHNOLOGY CENTER 1762**

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Art Unit	: 1762	Customer No.: 035811
Examiner	: Jimmy Lin	
Serial No.	: 10/055,770	
Filed	: January 23, 2002	
Inventors	: Shigeo Fujimori	Docket No.: 1023-02
	: Yoshiyuki Kitamura	
	: Hiromitsu Kanamori	Confirmation No.: 8726
	: Takeshi Ikeda	
	: Tetsuo Oka	
Title	: INTEGRATED MASK AND METHOD AND	
	: APPARATUS FOR MANUFACTURING	
	: ORGANIC EL DEVICE USING THE SAME	Dated: May 31, 2007

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Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Sir:

This is submitted in response to the Official Action dated February 7, 2007.

Claims 11 and 14 stand rejected under 35 U.S.C. §103 over the combination of Shigeo with Clark. The Applicants note with appreciation the Examiner's detailed comments concerning the Applicants' priority application JP 2001-023474. The Applicants continue to respectfully submit that Clark is not prior art and the Applicants' JP '474 priority document fully supports the claimed subject matter. The Applicants accordingly enclose for the Examiner's convenience a Comparison Chart that includes the subject matter of Claims 11 and 14 on the left-hand side and the actual text and specific location of the language from the Applicants' JP '474 priority document on the right-hand side.

The Applicants invite the Examiner's attention in particular to the boxes spanning Pages 1 and 2 of that enclosure with respect to support for the language "...using alignment marks formed on said integrated mask and said single substrate, ..." It can be seen that the support for such language begins on Page 15 at Lines 22 – 26 wherein the alignment marks 6 of the integrated mask 1 are observed by the camera 130 and the positions thereof are determined and memorized by an imaging process unit. Then, on Page 16 at Lines 8 – 11, JP '474 discloses that